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AMENDMENT TRANSMITTAL LETTER				Docket No. 0171-1045P	
Application No. 10/724,734-Conf. #2079	Filing Date December 2, 2003	Examiner S. D. Rosasco	Art Unit 1756		
Applicant(s): Hideo KANEKO et al.					
Invention: METHODS OF MANUFACTURING PHOTOMASK BLANK AND PHOTOMASK					
MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450					
Transmitted herewith is an amendment in the above-identified application.					
The fee has been calculated and is transmitted as shown below.					
CLAIMS AS AMENDED					
	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate	
Total Claims	13	- 20 =	0	x 50.00	0.00
Independent Claims	1	- 3 =	0	x 200.00	0.00
Multiple Dependent Claims (check if applicable) <input type="checkbox"/>					
Other fee (please specify):					
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT:					0.00
<input checked="" type="checkbox"/> Large Entity <input type="checkbox"/> Small Entity					
<input checked="" type="checkbox"/> No additional fee is required for this amendment.					
<input type="checkbox"/> Please charge Deposit Account No. _____ in the amount of \$ _____ A duplicate copy of this sheet is enclosed.					
<input type="checkbox"/> A check in the amount of \$ _____ is enclosed.					
<input type="checkbox"/> Payment by credit card. Form PTO-2038 is attached.					
<input checked="" type="checkbox"/> The Director is hereby authorized to charge and credit Deposit Account No. <u>02-2448</u> as described below. A duplicate copy of this sheet is enclosed.					
<input checked="" type="checkbox"/> Credit any overpayment.					
<input checked="" type="checkbox"/> Charge any additional filing or application processing fees required under 37 CFR 1.16 and 1.17.					
Gerald M. Murphy, Jr. Attorney Reg. No.: 28,977 BIRCH, STEWART, KOLASCH & BIRCH, LLP 8110 Gatehouse Road Suite 100 East P.O. Box 747 Falls Church, Virginia 22040-0747 (703) 205-8000				Dated: <u>September 29, 2006</u>	



Docket No.: 0171-1045P
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Hideo KANEKO et al.

Application No.: 10/724,734

Confirmation No.: 2079

Filed: December 2, 2003

Art Unit: 1756

For: METHODS OF MANUFACTURING
PHOTOMASK BLANK AND PHOTOMASK

Examiner: S. D. Rosasco

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In reply to the outstanding Office Action dated July 18, 2006, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

This Reply includes: An Amended Set of Claims; and
Remarks.